

EECE488 Analog CMOS Integrated Circuit Design
Assignment 1
Due: Tuesday October 8th, 2013 at 9:30am

1. The transit frequency, f_T , of a MOS transistor is defined as the frequency at which the small-signal current gain of the device drops to unity while the source and drain terminals of the device are held at ac ground.
 - a) Given that in the subthreshold region the drain current of the device is:

$$I_D = I_0 e^{\frac{V_{GS}}{\eta V_T}}$$

where $\eta \approx 1.5$ and $V_T = kT/q$ ($V_T = 26\text{mV}$ at the room temperature), find an expression for the f_T of a MOS device that is operating in the subthreshold region.

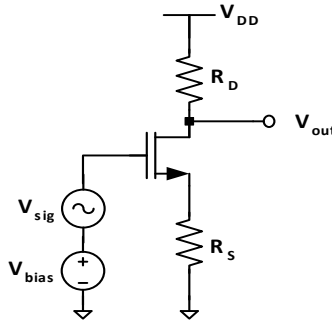
- b) Compare the result of part (a) with the f_T of the same transistor operating in the active region and comment on the relative value of f_T of the transistor when it is operating in active region compared to when it is in subthreshold region.

(Hint: To calculate f_T use the small-signal model and include relevant device capacitors).

2. In the following circuit, assuming that the transistor is operating in the saturation region:

- a) Find the required V_{bias} for which the dc value of the V_{out} is 1.44V.
 - b) Is the assumption that the transistor is in the saturation region correct?
 - c) Find the small-signal gain $V_{\text{out}}/V_{\text{sig}}$.

Assume $\lambda = 0$, $\gamma = 1\text{V}^{1/2}$, $2\Phi_F = 0.64\text{V}$, $V_{\text{TH0}} = 0.4\text{V}$, $\mu_n C_{\text{ox}} = 800 \mu\text{A}/\text{V}^2$, $(W/L)_{\text{NMOS}} = 20$, $R_D = R_S = 0.5\text{k}\Omega$, and $V_{\text{DD}} = 1.8\text{V}$.



3. Use HSPICE and the 0.35- μm CMOS technology file to draw I_X versus V_X for the following circuits. Sweep V_X from 0 to 1.8 V. Is there any similarity between the two circuits? (make sure to include your HSPICE code)

